

Scheme 1 Cyclotrimerization of cyanate ester resin



Scheme 2 Presumed curing mechanism of cyanate ester resin in the presence of o-DAMP



Figure 1 Chemical structures of the compounds used in this study



Figure 2 DSC thermograms of BADCYs in the absence and presence of the phenolic compounds (OCN/OH = 1.0/0.05).



Figure 3 DSC thermograms of BADCYs in the absence and presence of phenol, *o*-DAMP and *p*-DAMP (OCN/OH = 1.0/0.05).



Figure 4 FT-IR spectra of (a) BADCY/*o*-DAMP, (b) BADCY/*p*-DAMP and (c) BADCY/phenol before the DSC measurements (OCN/OH = 1.0/0.05).



Figure 5 FT-IR spectra of BADCY/*o*-DAMPs cured at (a) $120 \degree C/2h + 150 \degree C/2h + 170 \degree C/6h$ and (b) $120 \degree C/2h + 150 \degree C/2h + 180 \degree C/6h$ (OCN/OH = 1.0/0.05).



Figure 6 DMA results of BADCY/*o*-DAMPs cured under different conditions (OCN/OH = 1.0/0.05).



Figure 7 FT-IR spectra of BADCY/o-DAMP at each curing step (OCN/OH = 1.0/0.05); (i) before curing, (ii) after 120 °C/2 h, (iii) after 120 °C/2 h + 150 °C/2 h, (iv) after 120 °C/2 h + 150 °C/2 h + 180 °C/2 h, and (v) after 120 °C/2 h + 150 °C/2 h + 180 °C/6 h.



Figure 8 Changes in A_{-OCN}/A_{-phenyl} for each curing step in BADCY/o-DAMP (OCN/OH = 1.0/0.05) and BADCY without a catalyst; (i) before curing, (ii) after 120 °C/2 h, (iii) after 120 °C/2 h + 150 °C/2 h, (iv) after 120 °C/2 h + 150 °C/2 h, and (v) after 120 °C/2 h + 150 °C/2 h + 180 °C/2 h, and (v) after 120 °C/2 h + 150 °C/2 h + 180 °C/6 h.



Figure 9 DMA results of BADCY/*o*-DAMPs with different ratios between OCN in BADCY and OH in *o*-DAMP.